WEST Search History

DATE: Friday, March 21, 2003

| Set Name side by side | Query | Hit Count | Set Name result set |
|-----------------------|---|-----------|---------------------|
| DB=US | PT,PGPB,JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ | | |
| L14 | L13 and (wafer near inspect\$4) | 8 | L14 |
| L13 | L7 and ((vertical near3 wafer) or (horizontal near2 shaft)) | 294 | L13 |
| L12 | L7 and ((semiconductor adj wafer\$2) near3 inspect\$4) | 13 | L12 |
| L11 | L7 AND L3 | 1 | L11 |
| L10 | L9 and (mass adj spectrometer) | 1 | L10 |
| L9 | L7 and L1 | 68 | L9 |
| L8 | L7 and L4 | 1 | L8 |
| L7 | (rotat\$5 near3 shaft) and ((vacuum adj chuck) or (suction adj cup)) | 2832 | L7 |
| L6 | L4 and (rotat\$5 near3 shaft) | 1 | L6 |
| L5 | L4 and (wafer\$2 near2 edge) | . 3 | L5 |
| L4 | L3 and L1 | 38 | L4 |
| L3 | ((ICP adj2 MS) or ((inductively adj coupled adj plasma) near2 (mass adj spectrometer))) | 548 | L3 |
| L2 | (analy\$5 near4 solvent) with ((ICP adj2 MS) or ((inductively adj coupled adj plasma) near2 (mass adj spectrometer))) | 4 | L2 |
| L1 | wafer and contaminat\$5 and solvent | 6384 | L1 |

END OF SEARCH HISTORY